

U.S. Department of Commerce, Patent and Trademark Office (PTO Form 1449 modified)		Docket No. WGEC/0014	Serial No. 10/668,927
INFORMATION DISCLOSURE STATEMENT BY APPLICANT		Applicant Ian Moore	Confirmation No. Unassigned
(Use several sheets if necessary)		Filing Date September 23, 2003	Group Unassigned
Examiner Unassigned			

U.S. Patent Documents

*Examiner Initial		Document Number	Issue Date	Applicant(s) Name	Class	Subclass	Filing Date If Appropriate
LS	A1	5,986,973	11/16/1999	Jericevic, et al.	367	24	09/04/1997
	A2						
	A3						
	A4			LS			
	A5						
	A6						
	A7						
	A8						

Foreign Patent Documents

*Examiner Initial		Document Number	Date	Country	Class	Subclass	Translation	
							YES	NO
LS	B1	EP 0 112 715	04/07/1984	European	G01V	1/36	<input checked="" type="checkbox"/>	<input type="checkbox"/>
	B2			LS			<input type="checkbox"/>	<input type="checkbox"/>
	B3						<input type="checkbox"/>	<input type="checkbox"/>

OTHER ART

*Examiner Initial		Including Author, Title, Date, Pertinent Pages, Etc.
LS	C1	Bannagi, M.S. & Verschuur, Eric., 2003, <i>Enhanced, post-stack multiple prediction using demigration</i> : Delphi consortium annual report, Chapter 6.
LS	C2	Van Dedem, E.J. & Verschuur, D.J., 2002, <i>3D surface-related multiple prediction: a sparse inversion approach</i> , Delphi Imaging and Characterization Project, Vol. XIII, Ann Report, Ch 6, pgs 95-134.
LS	C3	Kleemeyer, G., et al., <i>It's Magic - industry first 3D surface multiple elimination and pre-stack depth migration on ormen lange</i> : 65 th Ann. Internat. Mtgl, Eur. Assn. Geosci. Eng., Expanded Abstracts, B043.
LS	C4	Levin, S.A., 2002, <i>Prestack poststack 3D multiple prediction</i> : 72 nd Ann. Internat. Mtg., Soc. Expl. Geophys., Expanded Abstracts, SP3-05.
LS	C5	Nekut, A.G., <i>3D surface-related multiple prediction</i> , Amoco Exploration and Production Technology, 1998 SEG Expanded Abstracts.

Examiner /Lisa Sievers/ Date Considered 08/25/2006

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with your communication to applicant.